

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	18462	(substrate or wafer) with (resist or photosensitive) with (conduct\$3 or electric\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/30 19:31
L2	30818	(electr\$3 near2 field) with (substrate or wafer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/30 19:31
L3	787	1 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/30 19:32
L4	288029	(conduct\$3) near4 (metal\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/30 19:33
L5	187366	(conduct\$3) near4 (potential or volt\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/30 19:33
L6	56	3 and 4 and 5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/30 19:33

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